



Research and Development Technical Report ECOM - 0039 - 7

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MM&T Program for the Establishment of Production Techniques for High Power Bulk Semiconductor Limiters

7TH QUARTERLY REPORT

By

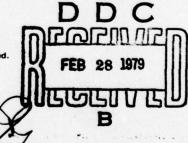
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R. BILOTTA

APRIL 1978

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MM&T PROGRAM FOR THE ESTABLISHMENT OF PRODUCTION TECHNIQUES FOR HIGH POWER BULK SEMICONDUCTOR LIMITERS

SEVENTH QUARTERLY REPORT
23 December 1977 to 22 March 1978

CONTRACT NO. DAAB07-76-C-0039

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Prepared By:

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FOR

U.S. ARMY ELECTRONICS COMMAND, FORT MONMOUTH, NJ 07703

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ABSTRACT

Confirmatory Samples consisting of twenty (20) X-band bulk limiters and multi-state clean-up diode limiters were assembled. Bulk limiters were fabricated from high resistivity silicon with $\rho = 8,000$ - 15,000 ohm-cm, p-type, uncompensated (111) orientation from Wacker Chemical Company. These bulk limiters exhibit 3.0 dB bandwidth of 0.71 - 1.2 GHz and low insertion loss of 0.4 - 0.6 dB. New passivation schemes are being investigated in order to reduce the insertion loss of bulk limiters and also to improve the power handling capability of the bulk limiters.

PURPOSE

The objective of this program is to establish a production capability to manufacture High Power Bulk Semiconductor Limiters per U.S. Army Electronics Command Technical Requirements SCS-486.

The specification covers X-band high power bulk semiconductor limiter and low power multistage clean up limiter. Four fundamental requirements are detailed in the specifications. They are, (1) recovery time, (2) high power capability, (3) insertion loss, and (4) VSWR.

A total of fifteen (15) engineering sample limiters, twenty (20) confirmatory sample limiters and fifty (50) pilot run production limiters will be supplied. A pilot line capable of producing 100 bulk semiconductor limiters per month will be demonstrated. Reports and documentation as required in Sections E, F, G, and H of DAAB07-76-Q-0040 and as detailed in Section 3.5 of ECIPPR No. 15, dated December 1976, will be provided.

The program divides into the following four phases, Phase I - Engineering Samples (300 days), Phase II - Confirmatory Sample Production (240 days), Phase III - Pilot Line Production (180 days), and Phase IV - Final Documentation (30 days). The total program duration is 750 days.

During Phase I of this program, a number of factors in fabricating bulk semiconductor limiters are being investigated. These include iris formation, circuit configuration, material characterization and chip mounting. Efforts during Phase I will be directed toward selecting a single limiter design capable of meeting the objectives of SCS-486.

The optimum device design will be chosen at the end of Phase I. In Phases II, III, and IV a single device design will be produced.

The major effort of this program will be realization of a single bulk limiter design which meets all the objectives of SCS-486. Individually, any of the goals described can be currently obtained. Recognizably, it is the development of a single component design which achieves all of the desired performance parameters that is the formidable engineering and manufacturing endeavor.

I. OBJECTIVE

The objective of the current Manufacturing Methods and Technology Engineering program is to establish the producibility of the X-band bulk semiconductor limiter and the X-band bulk semiconductor lower power diode multistage limiter by mass production techniques. Achieving the performance goals of the program represents a formidable engineering task. These goals, from SCS-486 are summarized below.

A. Function Description

The high power, solid state, limiter described herein will operate in the frequency band 9.0 - 9.65 GHz. A multi-stage configuration is acceptable with the first stage incorporating the principle of avalanche breakdown of near-intrinsic silicon to achieve isolation. This device will be mounted in a fixed tuned resonant waveguide cavity designed to provide the necessary avalanche field conditions. The second stage shall be either a bulk effect device or a common semiconductor diode limiter. Both limiter devices will be mounted in a common structure and no external bias or drive will be necessary for its operation. The receiver protector is required to operate in unpressurized conditions.

B. Mechanical Characteristics

The bulk semiconductor limiter structure will have the following performance objectives:

Weight:

7.0 oz max

Input Flange:

mates with UG-40B/U choke flange

Output Flange:

mates with UG-135/U cover flange

Mounting Position:

any

Cooling:

conduction

C. Electrical Characteristics

The bulk semiconductor limiter will have the following objectives:

Peak RF input power: 30 kW, duty cycle = 0.001%

l μ sec pulses continuous: 10 kW, duty cycle = 0.01 %

Insertion loss: 0.7 dB (max)

Low level VSWR: 1.4:1 (max)

Recovery time: 0.8 µsec (max)

Flat leakage: 50 mW (max), for 30 kW,

0.001 duty cycle, 1 µsec pulse

Spike leakage: 750 mW (max), for 30 kW,

0.001 duty cycle, 1 µsec pulse

External bias: none

D. Absolute Rating Objectives

PARAMETER	SYMBOL	MIN	MAX	UNIT
Frequency	F	9.0	9.65	GHz
Peak Power	P		30	kW
Average Power	Pa		100	w
Ambient Temp	T _A	-55	+85	°c
Altitude			50,000	ft

II. INTRODUCTION

This report covers the period from 23 December 1977 to 22 March 1978. During this period, the work was concentrated in the areas of semiconductor wafer processing, device fabrication and RF testing of bulk limiters.

Twenty (20) Confirmatory Samples were fabricated and tested for their RF performance. New passivation schemes are being investigated in order to reduce the insertion loss of bulk limiters and also to improve the power handling capability of the bulk limiters.

The subsequent sections of this report describes in greater detail the work performed and results achieved to date.

III. FABRICATION AND RF TESTING OF THE CONFIRMATORY SAMPLES

During this quarter, bulk limiters were fabricated for the twenty (20) piece Confirmatory Sample requirement. Bulk limiter chips from various runs were mounted in X-band gold plated copper irises and then bulk limiters were tuned to the proper center frequency. The bulk limiters were tested for bandwidth, recovery time, insertion loss, and power handling capability. These results are shown in Table I.

The clean-up limiters were then fabricated and pretuned for insertion loss, VSWR and isolation.

Subsequently, each bulk limiter was mated with a clean-up limiter and the entire package was finally tuned for insertion loss and VSWR.

This low RF power performance data is given in Table II.

Final tuning of the package was accomplished solely by adjusting the position of the clean-up limiters and tuning screws. No tuning was performed on the bulk limiters after its center frequency had been set.

BULK LIMITER	f o (MHz)	BW (MHz)	RECOVERY TIME (μs)	flat fower (W)
16A - 12	9300	1060	1.5	71
16A -2	9340	765	2.1	50
16A -47	9325	1010	2.3	90
17D-13	9320	840	1.2	50
16A -45	9350	1140	1.9	95
16A-1A	9325	910	1.8	55
17A -42	9350	970	1.2	63
16A -46	9320	1050	1.9	80
17D-18	9325	1050	1.4	75
17D-20	9325	980	1.7	63
17D-19	9325	950	1.3	63
17D-16	9325	830	1.4	55
17D-12	9325	1170	1.8	71
16A -3	9325	810	2.0	37
16A -40	9320	1000	2.0	80
26B-4	9245	1115	2.0	71
16 -13	9300	1115	2.2	180
27 -9	9325	780	1.9	100
27 -5	9325	770	1.8	70
27 -2	9350	985	2.4	130

NOTE: All high power test results were taken with:

 $\bullet P_{IN} = 20 kW$

• Pulse Width = 0.25 μs

• Duty Cycle = 0.001

TABLE I BULK LIMITER TEST RESULTS

BULK LIMITER	vswr	INSERTION LOSS (dB)
16A - 12	1.3	0.8
16A -2	1.45	0.7
16A -47	1.32	0.7
17D-13	1.32	0.7
16A -45	1.27	0.7
16A - 1A	1.36	0.6
17A -42	1.34	0.7
16A - 46	1.28	0.6
17D-18	1.31	0.6
17D-20	1.33	1.0
17D-19	1.38	0.9
17D-16	1.43	1.2
17D-12	1.60	0.8
17A -3	1.48	0.7
16A-40	1.29	0.8
26B-4	1.50	0.9
16A - 13	1.33	0.7
27 -9	1.53	1.2
27 -5	1.53	1.1
27 -2	1.38	0.9

NOTE: Data shown represents maximum values taken in a swept frequency measurement. The required measurement for VSWR is 1.7, maximum; for insertion loss it is 1.3 dB, maximum.

TABLE II BULK -- CLEAN-UP LIMITER PACKAGE LOW POWER TEST RESULTS

IV. CONCLUSION

Confirmatory Samples, consisting of twenty (20) X-band bulk limiters and multi-stage clean-up diode limiters have been assembled. Bulk limiters were fabricated from high resistivity silicon with $\rho=8,000-15,000$ ohm-cm, p-type, uncompensated (111) orientation from Wacker Chemical Company. These bulk limiters exhibit 3.0 dB bandwidth of 0.71 - 1.2 GHz and low insertion loss of 0.4 - 0.6 dB.

V. PROGRAM FOR THE NEXT QUARTER

During the next quarter, Confirmatory Samples will be submitted to Quality Control for environmental testing according to Specification SCS-486. The high power life test will be conducted on the bulk limiter assemblies.

VI. <u>IDENTIFICATION OF PERSONNEL</u>

During this quarter, the following technical personnel contributed to this program.

TITLE	MANHOURS
Project Manager	25
Processing Engineer	5
Limiter Engineer	5
Engineering Assistant (Fabrication)	15
Engineering Assistant (Test)	720
Assembly / Process	860

()

High Power Bulk Semiconductor Limiter

1. SCOPE: This specification describes a passive, solid state, receiver protector using a bulk semiconductor limiter in combination with a semiconductor diode limiter. Limiter operation will provide isolation from x-Band pulses up to 30 km over a variety of test conditions.

2. APPLICABLE DOCUMENTS

2.1 Documents. - The following documents, of issue in effect on the date of invitation for bids, form a part of this specification to the extent specified herein.

SPECIFICATIONS

MILITARY

MIL-E-1 MIL-P-11268 General Specification for Electron Tube Parts, Materials, and Processes Used in Electronic Equipment

STANDARDS

12

-145

MILITARY

MIL-STD-105

Sampling Procedures and Tables for Inspection

by Attributes

MIL-STD-202

Test Methods for Electronic and Electrical Components Parts

MIL-STD-1311A Microwave Oscillator Test Methods

(Copies of specifications, standards and publications required by contractors in connection with specific procurement functions should be obtained from the procuring activity or as directed by the contracting officer. Both the title and number of symbol should be stipulated when requesting copies.)

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3.1 Function Description. - The high power, solid state, limiter specified herein will operate in the frequency bond 9.0 - 9.65 GHZ. A multi-stage configuration is acceptable with the first stage incorporating the principle of avalanche breakdown of near-intrinsic silicon to achieve isolation. This device will be mounted in a fixed turned resonant waveguide cavity designed to provide the necessary avalanche field conditions. The second stage shall be either a bulk effect device or a semiconductor diode limiter. Both limiter devices will be mounted in a common structure and no external bias or drive will be necessary for its operation. The receiver protector is required to operate in unpressurized conditions.

. ...

- 3.2 Mechanical Characteristics. The bulk semiconductor limiter structure will conform to the following requirements:
 - (a) Weight ZO oz max

(1)

- (b) Input flange mates with UG-40B/U choke flange
- (c) Output flange mates with UG-135/U cover flange
- (d) Mounting position any
- (e) Cooling conduction
- 3.2.1 Physical Dimensions. The bulk semiconductor limiter shall conform to Figure 1.
 - 3.2.2 Construction. Parts and materials will be in accordance with MIL-P-11268.
- 3.3 Electrical characteristics. The bulk semiconductor limiter will conform to the following requirements:
 - (a) Peak Rf Input power, : 30 kw, Du = .001

 1/(sec pulses continuous 10 kw, Du = .01
 - (b) Insertion Loss : 0.7dB (max)
 - (c) Low Level VSWR : 1.4:1 (max)
 - (d) Recovery Time : 0.84 sec (max)
 - (e) Flat Leakage : 50 mw (max), for 30 kw, .001 duty cycle, 1 usec pulse
 - (f) Spike Leakage : 750 mw (max), for 30 kw, .001 duty cycle, 1 usec
 - (g) external bias : none

3.4 Absolute Ratings

Parameter	Symbol	Min	Max	Unit
Frequency	F	9.0	9.65	GHZ
Peak Power	P		30	kw
Average Power	Pa		100	w
Ambient Temp.	TA	-55	+85	°C
Altitude	_		50,000	· ft

- 3.5 Marking. Each bulk semiconductor limiter shall be marked with the following information:
 - (a) Manufacturer's model number
 - (b) Manufacturer's serial number, individually for each limiter.
 - (c) rf input port.

(d) rf output port.

4. QUALITY ASSURANCE PROVISIONS

4.1 Inspection.

4.1.1 Responsibility for inspection. - The contractor is responsible for the performance of all inspection requirements as specified herein. The contractor may utilize his own facilities or any commercial laboratory acceptable to the government. The government reserves the right to perform any of the inspections set forth in the specification where such inspections are deemed necessary to assure supplies and services conform to prescribed requirements. Inspection records of the examinations and tests shall be kept complete and available to the government.

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- 4.1.2 Test equipment c inspection facilities. Test equi, ent and inspection facilities shall be of sufficient accuracy, quality, and quantity to permit performance of the required inspection. The supplier shall establish calibration of inspection equipment to the satisfaction of the government.
- 4.2 Classification of inspection. The examination and testing of limiters shall be classified as follows:
 - a. First article inspection (see 4.3).
 - b. Quality conformance inspection (see 4.4.).
- 4.3 First article inspection. First article inspection shall be performed by the supplier, after award of contract and prior to production at a location acceptable to the government. It shall be performed on sample units which have been produced with equipment and procedures which will be used in production. This inspection shall consist of QCI-1, QCI-2 and QCI-3 inspection in accordance with 4.4.1, 4.4.2 and 4.4.3.
- 4.3.1 Sample. Twenty (20) limiters shall be submitted for first article inspection.
- P. 14.4 Quality Conformance Inspection.
- 4.4.1 Quality conformance inspection Part 1 (QCI-1). Every limiter shall be tested in all positions of the Quality Conformance Inspection Part 1 (QCI-1). No failures shall be permitted.
- 4.4.2 Quality conformance inspection Part 2 (QCI-2). The Quality Conformance Inspection Part 2 (QCI-2) shall be performed in accurdance with MIL-STD-105, Inspection Level SI with an AQL of 6.5%. In the event of lot rejection, tightened inspection procedures shall be invoked. Normal inspection shall be resumed when two (2) consecutive lots have conformed with QCI-2 tests. If the lot size is less than 50 limiters, the sample size shall be one (1) with an acceptance number of zero (0). For purposes of inspection, the lot size shall be one (1) month's production.
 - 4.4.3 Quality conformance inspection Part 3 (OCI-3). Three limiters shall undergo continuous life testing for a min. of 2500 hrs. No failures shall be permitted.
 - 4.5 Detailed listings of quality conformance inspection tests. Quality conformance inspection tests shall be conducted in accordance with Table I (OCI-1), Table II (OCI-2), and Table III (QCI-3).

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ens	PRR Pulses/sec	1000±25	1	1000±25	10,000 ±150	1000 ±25	1	
Test Conditions	الم يود الم يود	1.0±0.1	CW	1.0±0.1	1.0±0.1	1.40.1	.	-
	Po · Watts	000° + 200° .	0.001	1	10,000 ± 250	32,000 ± 500	0	0
	Fo GHZ	9.0, 9.375, 9.65±.01	9.0 - 9.65 ± .01	9.0, 9.375, 9.65±.01	9.0, 9.375, 9.65±.01	9.375±.01	1	1
	_^° V	25±3	25±3	25±3	2543	25±3	1	25±3
1,6	Unit	101	IC 2.	17.3	. TC 4	10.5	10.6	TC 7

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0	Mil Standard	Application Method	Conditi (Symbol	Limits Lower Upper	per	Units .	C, S
Maximum Leakage (flat)	1311A	4452A	1 21	4	S		WE	1,3
Moximum Leckage (spike)	, 1311A	4452A	1 21	~ ~	750) NE	2,3
Insertion Loss	1311A . 4416	4416	TC 2 ·	n .	0.7		-8	3,4
Low Level VSWR	1311A	4473	TC 2	Ь	1.4:1	-	l	3,4,5
Recovery Time	1311A	4471B (Mathod B)	TC 1	بر	0.8		Jase T	3,8
Firing Power	1311A	4496	TC 3	PFR ·	150		wu.	3,6,8

Quality Conformence Inspection- Part 1 (Ge1.1)

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Characteristic (phase)

Recovery

Chorocteristic

Recovery

(amplitude)

Moximum Leakage

(flot)

13

Maximum Leakage

(spike)

Maximum Leakage

(Elas)

Moximum Leokoge

(spike)

202E

Vibration

Shock

Homitity

Cycling(non oper.)

Temperature

	Stendard Mothod	Application Method	Condition	Symbol	Lower U	Upper	Unit	Notes
Life Test	1311A 4551A	4551A	TC 5	-	2500		hours	=
Life Test End-Point (1)	1311A 4452A	4452A	10.1	~		1.0	watt	2,3
Life Test End-Point (2)	1311A 4416	4416	TC 2	۲.		6.0	-8	3,4
Life Test End-Point (3)	1311A	44718	1. 21	\ >		1.0	A sec	е п
Life Test End-Point (4)	13114	4452A	10.1	d.		75	WE.	1,3
Life Tast End-Point (5)	1311A	4496	1	PFR		170	WE	3,6

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requencies 9 000, 9.375, .9.650GHZ. The incident Rf pulse will have a risetime 50 nanoseconds maximum. Test configuration reference figure 4452 - 1b. The peak power measurement will be accomplished by calibrating the deflection of a sampling oscilloscope as described in section 3.2 paragraphs 3.2.1 and 3.2.2 of Mil-Std-1311A.

The maximum spike leakage shall not exceed the specified limits for test frequencies 9.000, 9.375, 9.650 GHZ. Oscilloscope calibration technique as described in section 3.2 paragraphs 3.2.1 and 3.2.2 of Mil-Std-1311A is applicable. Amplitude variation shall be recorded by observing the distribution of spike amplitudes for 1 minute time through open shutter of scope camera.

Quality conformance test to be made using multi-stage limiter. For example using the high power bulk stage followed by the limiter diode.

A swept frequency may be used.

Match Termination used in this test circuit shall have a VSWR of 1.05 or less.

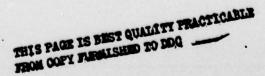
The firming power shall be defined as a 3b increase of limiter insertion loss mpared to the "cold" insertion loss.

Quality conformance test to be made using bulk semiconductor stage only.

For this specification the following abbreviations and symbols in addition to MIL-E-1 abbreviations and symbols shall apply; $T = time\ (recovery)$, $\Delta R_0 = variation$ of phase on recovery (total deviation at a fixed time), $\Delta R_0 = variation$ of amplitude on recovery (total deviation at a fixed time), $P_{FR} = time$ power.

The maximum variation in phase and amplitude as measured by dynamic phase and amplitude test facility shall not vary more than the specified limits over a 1 minute integration time period. Measurement to be made at a point 54sec from the cessation of 14sec input pulse.

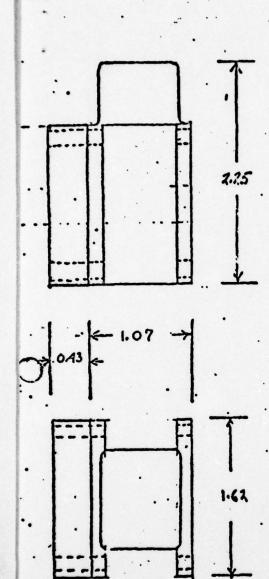
- . Measurement of parameters cited will follow the procedures outlined in QCI -1.
- The bulk semiconductor limiter shall operate over the entire duration of the life test. The spike leakage (P_s) will be periodically monitored. Life test will be interrupted each 720 \pm 20 hours intervals to permit testing of end of life test end points.

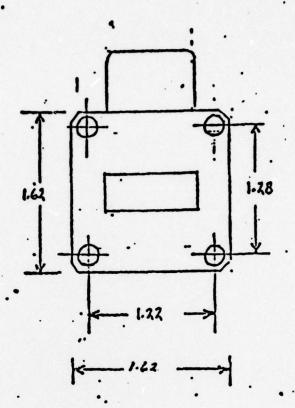


5.1 Packaging, Packing and Marking. - Packaging, packing and package arking shall be specified in the contract.

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LINE DRAWING





Notes :

- a) all dimensions in inches
- b) all tolerances ± 0.01 unless otherwise specified

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Commander Air Research & Development Comm ATTN: RDTCT Andrews Air Force Base Washington, DC 20330	1 and	Commander US Army Electronics Command ATTN: DRSEL-PP-I-PI-1 Fort Monmouth, NJ 07703	2

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NASA Manned Space Craft Center 1 Reliability and Flight Safety Div ATTN: Mr. Lawrence Steinhardt Houston, TX	General Electric Company 1 No. Concourse Bldg. Syracuse, NY 13212
Scientific & Technical Info Facility ATTN: Acquisition Branch (S-AK/DL) PO Box 8757 Baltimore (Wash. Intl A/P, MD 21240	General Motors Corp. 1 1 Delco Radio Div. ATTN: Dr. E. Jaumot, Jr. PO Box 1104 Kokomo, IN 46901
Avantek 1 ATTN: Mr. Thielan 3001 Cooper Rd Santa Clara, CA 95051	General Instrument Corp. 1 Semiconductor Products Group 600 W. John St. Hicksville, LI, NY 11802
AIL ATTN: Mr. Lou Cianciulli Commack Rd. Deer Park , LI, NY	Honeywell, Inc. 1 Semiconductor Products 2747 Fourth Ave. Minneapolis, MN 55408
American Electronics Laboratory 1 Richardson Rd Comar, PA Alpha Industries Inc. 1	Micro Electronics Lab 1 Hughes Aircraft Co 500 Superior Ave. Newport Beach, CA 92663
ATTN: Dr. W. K. Niblack 20 Sylvan Rd.	IBM 1. Components Div. ATTN: Mr. Al Kran
Woburn, MA 01801 Bendix Corporation 1 Semiconductor Div.	East Fishkill, Rt. 52 Hopewell Junction, NY 12533
ATTN: Mr. J. Ruskin South St. Holmdel, NJ 07733	KSC Semiconductor Corp. 1 ATTN: Mr. S. Cudletz, Pres. KSC Way (Katrina Rd). Chelmsford, MA 01824
Collins Radio Company 1 Cedar Rapids Div. ATTN: Mr. W. Caldwell Cedar Rapids, IO 52406	Arthur D. Little 1 Acorn Park ATTN: Dr. H. Rudenberg 15/206 Cambridge, MA 02140
General Micro-Electronics, Inc. 1 2920 San Ysidro Way Santa Clara, CA 95051	

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Raytheon Company Microwave Power Tube ATTN: R. E. Roberts Willow St. Waltham, MA 02154	1	Sanders Associates, Inc. ATTN: Microwave Dept. 95 Canal St. Nashua, NH	1
Motorola, Inc. ATTN: Mr. J. LaRue 5005 East McDowell Rd. Phoenix, AZ 85008	1	Texas Instruments Semiconductor Components Div. ATTN: Semiconductor Library PO Box 5012 Dallas, TX	1
Northrup Corporate Labs ATTN: Library 320-61 3401 West Broadway Hawthorne, CA 90250	1	Western Electric ATTN: Mr. R. Moore Maron & Vine Sts. Laureldale, PA	1
Philco Ford Corporation Microelectronics Div. Church Rd. Lansdale, PA 19446	1	Varian Associates Solid State Div. ATTN: Mr. J. Collard 8 Salem Rd. Beverly, MA 01803	1
Raytheon Company Semiconductor Operation ATTN: Mr. S. Weisner 350 Ellis St. Mountain View, CA 94040	1	Commander Air Force Materiels Lab Wright Patterson AFB ATTN: AFML/STE (Ms. E. Tarrar Dayton, OH 45433	1 nts)
Dr. Robert H. Rediker MIT Bldg. 13-3050 Cambridge, MA 02139		Dayton, On 40400	
Sprague Electric Co. ATTN: Mr. W.C. Donelan 87 Marshall St. North Adams, MA 01247	1		
Solitron Devices, Inc. 256 Oak Tree Rd. Tappan, NY 10983	1		